Contents

Theory of Photoemission 1
G. D. Mahan

I. Introduction 2
II. One Electron Theory 2
A. History 2
B. Atomic Photoionization 3
C. Photoemission from a Solid 8
D. Three Step Model 11
III. Angular Dependence in Simple Metals 12
A. Interband Transitions 12
B. Internal Photoemission: Direction 18
C. Internal Photoemission: Intensity 20
D. Experiments on Ag 23
IV. Plasmon Satellites in XPS 29
A. X-ray Photoelectron Spectroscopy 29
B. Electron Mean Free Path 30
C. Extrinsic vs. Intrinsic 34
V. Collective Effects 40
A. Phonons 40
B. Electron-Electron Interactions 42
C. Auger Decay 45
D. Auger and Phonon 47
References 51

The Use of Synchrotron Radiation in UPS: Theory and Results 54
W. E. Spicer

I. Introduction 54
II. Characteristics and Benefits of Synchrotron Radiation 56
III. Fundamentals of the Photoemission Process 58
A. Introduction 58
B. The Three-Step Model 59
C. Effect of Various Scattering Events and Contribution of Scattered Electrons 62

IV. Benefits of Synchrotron Radiation in Photoemission Studies 63
A. Introduction 63
V. Tuning Synchrotron Radiation to Minimize Electron Escape Depth and Thus Maximize Surface Sensitivity 65
A. Introduction 65
B. GaAs Core Shifts Due to Oxygen Adsorption 67
VI. Use of Photon Energy Dependence of Absorption Cross Section to Separate Photoemission from Two Sources Which Are Degenerate in Energy 72
A. Introduction 72
B. "Missing" Bonding Orbitals of CO Adsorbed on Metal 72
VII. Angularly Resolved Photoemission Electron Spectroscopy (ARPES) 76
A. Introduction 76
B. Studies of CO Adsorbed on Ni(100) 77
C. Use of ARPES to Obtain Information of the Bulk Band Structure 81
D. Discussion of ARPES 86
VIII. Conclusions 86
References 89

Angle Resolved Photoemission: Theoretical Interpretation of Results 93
A. Liebsch

I. Introduction 93
II. The Excitation Process 94
III. Atoms 99
IV. Molecules 104
1. Gas Phase Molecules 104
2. Oriented Molecules 107
V. Adsorbates 110
1. Core Levels 110
2. Surface Molecules 116
3. Chemisorbed Overlayers 119
VI. Clean Surfaces 125
1. Formalism 125
2. TaS_2 131
3. Cu(001) 134
4. Cu(111): Surface State 137
References 141

Chemisorption and Catalysis on Metals: Applications of Surface Spectroscopies 144
G. Ertl

I. Characterization of Chemisorbed Systems 144
1. The Molecular Nature of the Adsorbate 144
2. The Surface Concentration (Coverage) 147
3. Electronic Properties 150
4. Structure of Chemisorbed Layers 153
5. The Strength of the Substrate-Adsorbate Bond 155
6. Vibrations 157
II. Factors Influencing the Chemisorption Bond 159
1. The Nature of the Substrate and Adsorbate 159
2. The Local Character of the Chemisorption Bond 159
3. The Crystallographic Orientation of the Surface 162
4. The Role of Monoatomic Steps 164
5. The Adsorption Site 167
III. Interactions Between Adsorbed Particles 169
IV. Dynamics of Surface Processes 179
References 186

X-Ray Photoelectron Spectroscopy of Solids 192
G. K. Wertheim

I. Introduction 192
II. Valence Bands 198
A. Metals and Alloys 198
B. Compounds with Metallic Conductivity 202
C. Insulators 204
III. Photoemission from Open Shells 205
A. The Rare Earths 205
B. Transition Metal Compounds 208
IV. Core Level Spectra 211
A. Shake-Up Satellites 212
B. Configuration Interaction 213
C. Multiplet Splitting 215
D. Many-Body Effects in Metals 220
V. Summary 223
References 224

Current Problems in Auger Electron Spectroscopy 230
T. E. Gallon

Free Atom Auger Energies 230
Auger Emission from Solids 233

Auger Energies in the Solid State 235
Chemical Shifts in Auger Spectra 239
Line Broadening in the Solid State 242
Auger Spectra Involving Band Electrons 245
Quantitative Auger Spectroscopy 260
References 269

Studies of Adsorbate Electronic Structure Using Ion Neutralization and Photoemission Spectroscopies 273
H. D. Hagstrum

I. Introduction 273
II. Electronic Transition Processes 275
III. What We Can Learn from Studying Particle-Solid Electronic Interactions 277
IV. Experimental Apparatus and Techniques 278
V. Transition Rate and Probability Functions 282
VI. The Auger Neutralization Process 284
VII. Evidence for Variation of Atomic Energy Levels near a Surface 288
VIII. Transition Rate Parameters for Auger Neutralization 290
IX. Tunneling Processes for Unexcited Ions 291
X. The Auger De-Excitation Process 294
XI. Two-Stage Ejection Processes for Unexcited Ions 296
XII. Two-Stage Ejection Processes for Excited Ions 298
XIII. Oscillatory Ion Scattering from Surfaces 302
XIV. Kinetic Ejection of Electrons by Ions 304
XV. Energy Broadening in Auger Neutralization 305
XVI. The Method of Ion Neutralization Spectroscopy (INS) 309
XVII. What INS and UPS Measure 314
XVIII. Adsorbate Electronic Structure 317
XIX. Wave Function Variation Outside a Solid Surface 319
XX. Uniqueness and Limitations of INS 321
XXI. References 322

Introduction to Secondary Ion Mass Spectrometry (SIMS) . . 324
H. W. Werner

1. Introduction 324
2. Theory of SIMS 328
2.1. Physical Basis 328
2.2. Basic Formula for a SIMS Analysis 338
2.3. Basic Experimental Embodiment 353

2.4. Type of Information Obtainable 359
2.4.1. Qualitative or Quantitative Survey Analysis 359
2.4.2. Surface Analysis 359
2.4.3. Depth Analysis 359
2.4.4. Element Mapping 361
2.4.5. Structural Analysis 367
2.5. Derived and Related Techniques 372
2.5.1. Neutral Particle Bombardment 372
2.5.2. Post Ionization of Sputtered Neutral Particles 373
2.5.3. Bombardment Induced Light Emission (BLE) 374
2.5.4. Laser Induced Ion Emission 375
3. Practice of Technique 375
3.1. Types of Instruments 375
3.1.1. Primary Ion Sources 375
3.1.2. Mass Analysers 377
3.1.3. Ion Detection 393
3.1.4. Use of Computers in SIMS Instrumentation 407
4. Comparison of SIMS with Other Thin Film Analytical Techniques 416
Conclusion 422
Appendix I 423
Appendix II 433
References 436

Author Index 443

Subject Index 467